PATENT ASSIGNMENT COVER SHEET

Electronic Version v1.1 Stylesheet Version v1.2

EPAS ID: PAT2606083

SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	SECURITY AGREEMENT

CONVEYING PARTY DATA

Name	Execution Date
RAVE N.P., INC.	11/06/2013

RECEIVING PARTY DATA

Name:	AVIDBANK CORPORATE FINANCE, A DIVISION OF AVIDBANK	
Street Address:	400 EMERSON STREET	
City:	PALO ALTO	
State/Country:	CALIFORNIA	
Postal Code:	94301	

PROPERTY NUMBERS Total: 23

Property Type	Number
Patent Number:	8568018
Patent Number:	8454409
Patent Number:	5836809
Patent Number:	5837064
Patent Number:	5804826
Patent Number:	6173916
Patent Number:	5611491
Patent Number:	5561527
Patent Number:	6852173
Patent Number:	7056391
Patent Number:	6949145
Patent Number:	6500758
Patent Number:	5989355
Patent Number:	6146466
Patent Number:	5766368
	DATENT

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Patent Number:	5853962
Patent Number:	5806544
Patent Number:	6099396
Patent Number:	6066032
Patent Number:	6276169
Patent Number:	6405560
Patent Number:	7564625
Patent Number:	D451937

CORRESPONDENCE DATA

Fax Number: (858)550-6420 **Phone**: 858-550-6403

Email: erin.obrien@cooley.com

Correspondence will be sent via US Mail when the email attempt is unsuccessful.

Correspondent Name: ERIN O'BRIEN
Address Line 1: C/O COOLEY LLP
Address Line 2: 4401 EASTGATE MALL

Address Line 4: SAN DIEGO, CALIFORNIA 92121

ATTORNEY DOCKET NUMBER:	308866-167 RAVE NP
NAME OF SUBMITTER:	ERIN O'BRIEN
Signature:	/Erin O'Brien/
Date:	11/06/2013

Total Attachments: 6

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INTELLECTUAL PROPERTY SECURITY AGREEMENT

THIS INTELLECTUAL PROPERTY SECURITY AGREEMENT is entered into as of November 2013 by and between AVIDBANK CORPORATE FINANCE, A DIVISION OF AVIDBANK, a California corporation ("Bank") and RAVE N.P., INC., a Delaware corporation ("Grantor").

RECITALS

Bank has agreed to make certain advances of money and to extend certain financial accommodations to Grantor in the amounts and manner set forth in that certain Loan and Security Agreement by and between Bank, Grantor and RAVE LLC, a California limited liability (as amended from time to time, the "Loan Agreement") dated of even date herewith. Capitalized terms used herein have the meaning assigned in the Loan Agreement. Bank is willing to make the financial accommodations to Grantor, but only upon the condition, among others, that Grantor shall grant to Bank a security interest in all of such Grantor's right title, and interest in, to and under all of the Collateral whether presently existing or hereafter acquired

Now, THEREFORE, Grantor agrees as follows:

AGREEMENT

To secure performance of Grantor's obligations under the Loan Agreement, Grantor grants to Bank a security interest in all of Grantor's right, title and interest in Grantor's intellectual property (including without limitation those Copyrights, Patents and Trademarks listed on Exhibits A, B and C hereto), including without limitation all proceeds thereof (such as, by way of example but not by way of limitation, license royalties and proceeds of infringement suits). This security interest is granted in conjunction with the security interest granted to Bank under the Loan Agreement. Each right, power and remedy of Bank provided for herein shall not preclude the simultaneous or later exercise by Bank of any or all other rights, powers or remedies.

This Agreement may be executed in two or more counterparts, each of which shall be deemed an original but all of which together shall constitute the same instrument.

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Address of Borrower:

RAVE N.P., INC.

430 S. Congress Ave., Suite 7
Delray Beach, FL 33445
FAX:
Attn: Barry Hopkins (CEO), or Rick Greece (CFO)

Address of Bank:

AVIDBANK CORPORATE FINANCE,
A DIVISION OF AVIDBANK

400 Emerson Street
Palo Alto, CA 94301

FAX: (650) 323-6527 Attn: Jon Comeau

In WITNESS WHEREOF, the parties have caused this Intellectual Property Security Agreement to be duly

EXHIBIT A

Copyrights

Please Check Box if No Copyrights Exist \square

Title	Registration Number	Registration Date	
MASKCLEAN 150 SOFTWARE	TX0007197625	2/17/2010	
WAFERCLEAN 1600 SOFTWARE	TX0005954215	2/27/2004	
WAFERCLEAN 1600 SOFTWARE	TX0005903905	3/28/2004	

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Ехнівіт В

Patents

Please Check Box if N	Serial/ Patent	t Application/ Issue	
Title		Number	Date
Fluid Injection Assembly for Nozzles	U.S.	8,568,018	Issued 10/29/13
CO2 Nozzles	U.S.	8,454,409	Issued 6/4/13
Method for selective metal film layer removal using CO			
jet spray	Canada	2,422,062	Issued 3/18/11
App & method for cleaning large glass plates using linear arrays of CO2 jet spray nozzles	U.S.	5,836,809	Issued 11/17/98
Electrostatic discharge protection of static sensitive devices cleaned with CO2 spray CO2 liquid and gas sensor apparatus for use with jet	U.S.	5,837,064	Issued 11/17/98
spray	U.S.	5,804,826	Issued 9/8/98
CO2 Jet spray nozzles with multiple orifices	U.S.	6,173,916	Issued 1/16/01
CO2 Jet Spray Nozzles with Multiple Orifices	EP	721801	Issued
CO2 Jet Spray Nozzles with Multiple Orifices	U.K.	721801	Issued 6/2/99
CO2 Jet Spray Nozzles with Multiple Orifices	France	721801	Issued 6/2/99
CO2 Jet Spray Nozzles with Multiple Orifices	Germany	721801	Issued 6/2/99
Modular CO2 jet spray device	U.S.	5,611,491	Issued 3/18/97
Optical sensing apparatus for CO2 jet spray	U.S.	5,561,527	Issued 10/1/96
Optical sensing apparatus for CO2 jet spray	EP	732150	Issued
Optical sensing apparatus for CO2 jet spray	Germany	69617502.9	Issued 12/5/01
Optical sensing apparatus for CO2 jet spray	France	732150	Issued 12/5/01
Optical sensing apparatus for CO2 jet spray	U.K.	732150	Issued 12/5/01
Dual Jet Spray Cleaner	Canada	2,122,402	Issued 10/6/98
Dual Jet Spray Cleaner	EP	622129	Issued
Dual Jet Spray Cleaner	Germany	69415381.08	Issued 12/23/98
Dual Jet Spray Cleaner	France	622129	Issued 12/23/98
Dual Jet Spray Cleaner	UK	622129	Issued 12/23/98
Fluid assisted cryogenic cleaning	Singapore	106923	Issued 10/31/06
Fluid assisted cryogenic cleaning	Taiwan	I 278927	Issued 4/11/07
Post-CMP cleaning of semiconductor wafer surfaces using comb. of aqueous &CO2 based cryogenic cleaning	China	100377836C	Issued 4/2/08
Post-CMP cleaning of semiconductor wafer surfaces using comb. of aqueous &CO2 based cryogenic cleaning Post-CMP cleaning of semiconductor wafer surfaces	Japan	3786651	Issued 3/31/06
using comb. of aqueous &CO2 based cryogenic cleaning Post-CMP cleaning of semiconductor wafer surfaces	Singapore	110342	Issued 1/31/07
using comb. of aqueous &CO2 based cryogenic cleaning	Taiwan	I 249783	Issued 2/21/06
Liquid-assisted cryogenic cleaning	U.S.	6,852,173	Issued 2/8/05

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Liquid-assisted cryogenic cleaning	U.S.	7,056,391	Issued 6/6/06
Vapor-assisted cryogenic cleaning	U.S.	6,949,145	Issued 9/27/05
Method for selective metal film layer removal using CO			
jet spray	U.S.	6,500,758	Issued 12/31/02
Method for selective metal film layer removal using CO	China	1815460.3	Issued 4/25/07
jet spray Method for selective metal film layer removal using CO	Clinia	1015400.5	1880Cu 4/25/07
jet spray	Japan	4009533	issued 9/7/07
Method for selective metal film layer removal using CO			
jet spray	Taiwan	172753	Issued 6/25/03
Method for selective metal film layer removal using CO			14004405
jet spray	Singapore	95341	Issued 10/31/05
Method for selective metal film layer removal using CO	EP	1317767	Issued
jet spray Method for selective metal film layer removal using CO	EP	1317/07	188000
jet spray	Germany	EP1317767	Issued 2/21/07
Method for selective metal film layer removal using CO			
jet spray	France	EP1317767	Issued 2/21/07
Method for selective metal film layer removal using CO			
jet spray	UK	EP1317767	Issued 2/21/07
Method for selective metal film layer removal using CO	· ·	ED101000	1 10/01/07
jet spray	Ireland	EP1317767	Issued 2/21/07
Method for selective metal film layer removal using CO	Italy	EP1317767	Issued 2/21/07
jet spray Method for selective metal film layer removal using CO	пату	EI 1317707	1550CG 2/21/07
jet spray	Netherlands	EP1317767	Issued 2/21/07
Apparatus for cleaning & testing precision components			
of hard drives and the like	U.S.	5,989,355	Issued 11/23/99
Use of electrostatic bias to clean non-electro. sensitive			
components with CO2 spray	U.S.	6,146,466	Issued 11/14/00
Integrated circuit chip module cleaning using CO2 jet	II G	5.766.269	inguis d 6/16/00
spray Photoresist and re-deposition removal using CO2 jet	U.S.	5,766,368	issued 6/16/98
spray	U.S.	5,853,962	Issued 12/29/98
CO2 jet spray disk cleaning system	U.S.	5,806,544	Issued 9/15/98
CO2 jet spray tilsk cleaning system CO2 jet spray pallet cleaning system	U.S.	6,099,396	Issued 8/8/00
		6,066,032	Issued 5/23/00
Wafer cleaning using a laser and CO2 snow Apparatus and method for analysis of impurities in liquid	U.S.	0,000,052	Issued 5/25/00
CO2	U.S.	6,276,169	Issued 8/21/01
	U.S.	6,405,560	Issued 6/18/01
Apparatus for analysis of impurities in liquid CO2	0.5.	0,702,200	133404 0/10/01
System and Method for Scanning Boom Microscope	US	7,564,625	Issued 7/21/09
Vertical Stepper Stage Apparatus	US	D451,937	Issued 12/11/01
· TITTE DISPLANTE SINGS . IPPARIEN		 -	

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EXHIBIT C

Trademarks

Please Check Box if No Trademarks Exist □

<u>Descr</u>	<u>iption</u>	Serial / Registration Number	Application /Registration Date
US	NANOSNOW	3,786,068	05/04/10
US	SNOWSTRIP	3,923,748	02/22/11
US	ECO-SNOW	2,429,388	02/20/01
JР	ECO-SNOW	4,902,470	
СН	ECO-SNOW	6,794,550	
US	WAFERCLEAN	2,436,017	03/13/01
US	WAFERCLEAN	3,434,792	05/27/08
₽	WAFERCLEAN	4,904,954	
US	VersaClean	3,316,127	10/23/07
JР	VersaClean	4,902,472	
US	MaskClean	3,316,126	10/23/07
JP	MaskClean	4,902,472	
US	PrecisionClean	3,070,328	03/21/06
US	PrecisionClean	3,316,697	10/23/07
JР	PrecisionClean	5,090,000	

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